



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

May 27, 2024

IGI Report Number

LG636481742

Description

LABORATORY GROWN DIAMOND

Shape and Cutting Style

OVAL MODIFIED BRILLIANT

Measurements

7.44 X 5.12 X 3.62 MM

GRADING RESULTS

Carat Weight

1.06 CARAT

Color Grade

E

Clarity Grade

VVS 1

ADDITIONAL GRADING INFORMATION

Polish

EXCELLENT

Symmetry

EXCELLENT

Fluorescence

NONE

Inscription(s)

IGI LG636481742

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.

Type IIa

LG636481742
Report verification at igi.org

DIAMOND REPORT



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OVAL MODIFIED BRILLIANT

Measurements

7.44 X 5.12 X 3.62 MM

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Carat Weight

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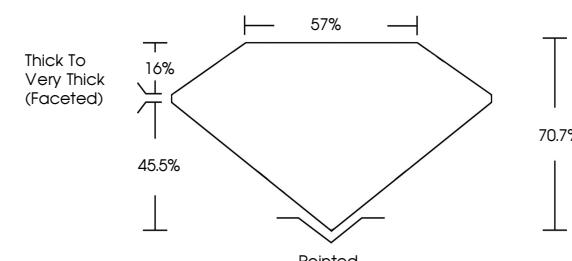
Color Grade

E

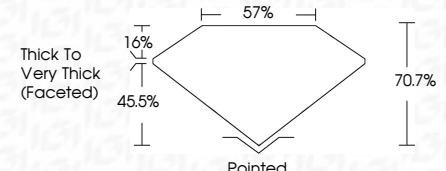
Clarity Grade

VVS 1

PROPORTIONS



Sample Image Used



ADDITIONAL GRADING INFORMATION

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EXCELLENT

Symmetry

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Fluorescence

NONE

Inscription(s)

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Type IIa

COLOR

D E F G H I J Faint Very Light Light

CLARITY

IF VS 1 - 2 VS 1 - 2 SI 1 - 2 I 1 - 3

Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included



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May 27, 2024	IGI Report No LG636481742	OVAL MODIFIED BRILLIANT	1.06 CARAT	E	VS 1	70.7%	57%	Pointed	EXCELLENT	EXCELLENT	NONE	IGI LG636481742
Carat Weight	7.44 X 5.12 X 3.62 MM	Color Grade	Pointed	Table Grade	Very Thick (Faceted)	Table Grade	Very Thick (Faceted)	Culet	Polish	Symmetry	Fluorescence	Inscription(s)
Clarity Grade		Depth										
Depth		Table Grade										
Table Grade		Culet										
Culet		Polish										
Polish		Symmetry										
Symmetry		Fluorescence										
Fluorescence		Inscription(s)										

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